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321/28, 317/24, 321/20, 321/22 2001.08.10 2001-244545(+2001JP-244545) (2003.02.26) C07C \*JP 2003055340-A

electronic material, has reduced dielectric constant, low refractive New alpha, index, and good chemical stability intermediates C2003-127189 for alpha-difluoro pharmaceuticals, photoacid sulfoxide compound generator used and

## NOVELTY

An  $\alpha$ , $\alpha$ -diffuoro sulfoxide compound (I), is new

## DETAILED DESCRIPTION

An α,α-difluoro sulfoxide compound having formula (I), is new.

R' = optionally substituted alkyl, optionally substituted aryl or

B(10-A10, 10-F2) C(10-A10, 10-F2) .2

 $R^2$  = optionally substituted alkyl or optionally substituted aryl; and optionally substituted cycloalkyl;

n = 0-2. compound having formula (II), tert-butyl, 3,5- difluorophenyl or 2,4-When n is 0 or 2, both R<sup>1</sup> and R<sup>2</sup> are phenyl groups. When n is 0, R<sup>1</sup> is difluorophenyl. methyl, p-chlorophenyl, or ethyl and R<sup>2</sup> is a substituted benzene

 $Y^1$ ,  $Y^2 = H$ , halogen or trifluoromethyl.  $\equiv$ 

(3) α,α-difluoro sulfone compound having formulae (VI,VIII,X and INDEPENDENT CLAIMS are included for the following: (2)  $\alpha, \alpha$ -difluoro sulfoxide compound having formula (IV); α,α- difluoro sulfoxide compound having formula (III); JP 2003055340-A+

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(V,VII,IX and XI);XII) and  $\alpha$ , $\alpha$ -difluoro sulfide compound having formulae

(4) pharmaceutical and agrochemical intermediate;(5) photoacid generator (intermediate);

(6) electronic material (intermediate);

(8) polymerization catalyst (intermediate). liquid crystal material (intermediate); and

 $R^3$  = optionally substituted 1-10C alkyl or optionally substituted 3- $Y^3-Y^5=H$ , halogen, optionally substituted 1-10C alkyl, optionally substituted 1-10C alkoxy, optionally substituted 3-10C cycloalkyl or optionally substituted 6-12C aryl;

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 $\mathbf{Y}^7 = \mathbf{Y}^3 - \mathbf{Y}^5$ 10C cycloalkyl;

trifluoromethyl or fluorine. is methyl or ethyl, and  $\dot{Y}^6$  and  $\dot{Y}^7$  are hydrogen atoms, halogen,  $^3$ , Y<sup>4</sup> and Y<sup>5</sup> are not hydrogen atoms simultaneously. When n is 0, R<sup>3</sup>

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USE

generator, electronic material, liquid crystal material and polymerization catalyst (all claimed). As intermediates for pharmaceuticals, agrochemicals, photoacid

ADVANTAGE

suppression, suppression of adverse reaction and mimic effect, when stability with respect to oxidation. sulfone compounds show active effect improvement, metabolism reduced dielectric constant, low refractive index, and good chemical used as intermediates. The compound has high substituent effect, The  $\alpha,\alpha$ -difluoro sulfoxide,  $\alpha,\alpha$ -difluoro sulfide and  $\alpha,\alpha$ -difluoro

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compound having formula (27) was obtained at an yield of 89 %. ⊠ e

and sodium hydroxide (14.4) dissolved in 174:87 solution of methanol and water, stirred at room temperature and extracted with ether. A

methanol and mixed with a mixture containing 46 ml of thiophenol

O-methyl phenacyl bromide (in g) (60) was dissolved in 270 ml of

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and His